

Session	Session Organizer	Institution	Email	Phone	Fax
<b>Basic Processes in Fully and Partially Ionized Plasmas</b>	<b>Frederick Skiff</b>	<b>University of Iowa</b>	<b>Frederick-skiff@uiowa.edu</b>	<b>319 335 0564</b>	<b>319 335 1753</b>
1.1 Basic Phenomena	Earl Scime	West Virginia University	<a href="mailto:escime@wvu.edu">escime@wvu.edu</a>	304 293 3422 ext. 1437	304 293 5732
1.2 Space Plasmas	Antony Peratt	<b>Los Alamos National Laboratory</b>	<b>alp@lanl</b>	<b>505 665 9407</b>	<b>505 665 7725</b>
1.3 Partially Ionized Plasmas	Igor Alexeff	<b>University of Tennessee</b>	<a href="mailto:alexeff@mail.ee.utk.edu">alexeff@mail.ee.utk.edu</a>	865 974 5467	<b>865 974 5492</b>
1.4 Computational Plasma Physics	John Petillo	SAIC – Boston	<a href="mailto:petilloj@saic.com">petilloj@saic.com</a>	781 221 7615	781 270 0063
1.5 Dusty Plasmas	Giovanni Lapenta	Los Alamos National Laboratory	<a href="mailto:lapenta@lanl.gov">lapenta@lanl.gov</a>	505 667 4394	505 665 3107
<b>Microwave generation and Plasma Interaction</b>	<b>Ron Gilgenbach</b>	<b>University of Michigan</b>	<b>rongilg@umich.edu</b>	<b>734 763 1261</b>	<b>734 763 4540</b>
2.1 Intense Beam Microwave Generation	Mike Haworth	<b>Air Force Research Laboratory</b>	<b>michael.haworth@kirtland.af.mil</b>		
2.2 Fast-Wave Devices	Monica Blank	Communications and Power Industries	<a href="mailto:monica.blank@cpii.com">monica.blank@cpii.com</a>	650 846 3557	650 852 9517
2.3 Slow-Wave Devices	David Whaley	L-3 Communications	<a href="mailto:david.whaley@L-3com.com">david.whaley@L-3com.com</a>	650 591 8411 xtn 2256	650 508 1956
2.4 Vacuum Microelectronics	John Booske	University of Wisconsin	<a href="mailto:booske@engr.wisc.edu">booske@engr.wisc.edu</a>	608 262 8548	608 262 1267
2.5 Codes and Modeling	John Luginsland	Numerex	<a href="mailto:John.Luginsland@NumerEx.com">John.Luginsland@NumerEx.com</a>	<b>607 277 4272</b>	
2.6 Microwave Systems	David Abe	<b>Naval Research Laboratory</b>	<a href="mailto:david.abe@nrl.navy.mil">david.abe@nrl.navy.mil</a>	202 767 0033	202 767 1280
2.7 Microwave Plasma Interaction	John Foster	<b>Ion Group, NASA Glenn Research Center</b>	<b>John.E.Foster@NASA.GOV</b>	<b>216 433 6131</b>	<b>216 433 8311</b>
<b>Charged Particle Beams and Sources</b>	<b>Sophie Chantrenne</b>	<b>KTECH Corporation</b>	<b>schantrenne@comcast.net</b>	<b>925 462 1739</b>	
3.1 Plasma, Ion and Electron Sources	Daniela Leitner	Lawrence Berkley National Laboratory	<a href="mailto:DLeitner@lbl.gov">DLeitner@lbl.gov</a>	510 486 7814	510 486 7983
3.2 Intense Electron and Ion Beams	Christophe Vermare	<b>CEA/PEM</b>	<b>christophe.vermare@free.fr</b>	<b>+33 326 030 614</b>	<b>+33 326 037 229</b>
<b>High Energy Density Plasmas and Applications</b>	<b>Chris Deeney</b>	<b>Sandia National Laboratories</b>	<b>cdeene@sandia.gov</b>	<b>505 845 3657</b>	<b>505 845 768</b>
4.1 Fusion ( Inertial, Magnetic and Alternate concepts)	Mark Herrmann	Sandia National Laboratory	<a href="mailto:mherrma@sandia.gov">mherrma@sandia.gov</a>	(505) 284 0236	(505) 845 7820
4.2 Ultrashort Pulse Lasers and Particle Acceleration	Farhat Beg	University of California San Diego	<a href="mailto:fbeg@ucsd.edu">fbeg@ucsd.edu</a>	(858) 822-1266	(858) 534-4543
4.3 Z-pinches and Radiation Sources	Brent Jones	Sandia National Laboratory	<a href="mailto:bmjones@sandia.gov">bmjones@sandia.gov</a>	(505) 284-9481	(505) 845-7685
4.4 High energy Density Physics	Ralph Schneider	Department of Energy	<a href="mailto:Ralph.Schneider@nnsa.doe.gov">Ralph.Schneider@nnsa.doe.gov</a>	(202) 586-0837	(202) 586-8005
<b>Industrial, Commercial, and Medical Applications of Plasma</b>	<b>Jeff Hopwood</b>	<b>Northeastern University</b>	<b>hopwood@ece.neu.edu</b>	<b>617 373 3006</b>	<b>617 373 8970</b>
5.1 Low-pressure Nonequilibrium Plasma Processing	Shahid Rauf	Freescale Semiconductor, Inc.	<a href="mailto:shahid.rauf@freescale.com">shahid.rauf@freescale.com</a>	512 933 3912	
5.2 Atmospheric-pressure Nonequilibrium Plasmas	Michael G. Kong	Loughborough University	<a href="mailto:m.g.kong@lboro.ac.uk">m.g.kong@lboro.ac.uk</a>	+44 1509 227075	+44 1509 227107
5.3 High Pressure and Thermal Plasma Processing	Joachim Heberlein	University of Minnesota	<a href="mailto:jvrh@umn.edu">jvrh@umn.edu</a>	612 625 4538	612 625 4344
5.4 Plasma Thrusters	Nikolaos A. Gatsonis	<b>Worcester Polytechnic Institute</b>	<a href="mailto:gatsonis@wpi.edu">gatsonis@wpi.edu</a>	508 831 5576	508-831 5680
5.5 Plasmas for Lighting	Richard Garner	Osram Sylvania	<a href="mailto:richard.garner@sylvania.com">richard.garner@sylvania.com</a>	978 750 1576	978 750 1799
5.6 Microplasmas and Flat-panel Displays	Kurt Becker	<b>Stevens Institute of Technology</b>	<a href="mailto:kbecker@stevens.edu">kbecker@stevens.edu</a>	201 216 5671	201 216 5638
5.7 Medical, Biological and Environmental Applications	Ravindra Joshi	Old Dominion University	<a href="mailto:rjoshi@odu.edu">rjoshi@odu.edu</a>	757 683 4827	757 683 3220

<b>Plasma Diagnostics</b>	<b>Vincent Donnelly</b>	<b>University of Houston</b>	<b>vmdonnelly@uh.edu</b>	<b>713-743-4313</b>	<b>713 743 4323</b>
6.1 Optical Diagnostics	Gregory Hebner	Sandia National Laboratories	gahebne@sandia.gov	505 844 6831	505 844 5459
6.2 Particle Diagnostics	Chikang Li	Massachusetts Institute of Technology	<a href="mailto:ckli@mit.edu">ckli@mit.edu</a>	617 253 0934	617 258 7929
6.3 X-ray Diagnostics	Robert Kaufmann	Lawrence Livermore National Laboratory			
<b>Pulsed Power and Other Plasma Applications</b>	<b>Mark Savage</b>	<b>Sandia National Laboratory</b>	<b>mesavag@sandia.gov</b>	<b>505 845 7462</b>	<b>505 845 7864</b>
7.1 Pulsed Power Technology and Other Applications	Mark Gilmore	University of New Mexico	<a href="mailto:gilmore@ece.unm.edu">gilmore@ece.unm.edu</a>	<b>505-277-2579</b>	<b>505-277-G221</b>
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